



Docket No.: M4065.0239/P239
(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Larry Hillyer et al

Confirmation No.: 5354

Application No.: 09/653,561

Allowed: July 21, 2006

Filed: August 31, 2000

Group Art Unit: 2812

For: METHOD AND MATERIAL FOR
REMOVING ETCH RESIDUE FROM
HIGH ASPECT RATIO CONTACT
SURFACES

Examiner: Alexander G Ghyka

**APPLICANT'S COMMENTS ON EXAMINER'S STATEMENT OF REASONS FOR
ALLOWANCE**

Commissioner for Patents
Washington, DC 20231

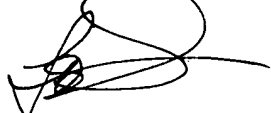
Dear Sir:

Applicants agree in part with the Examiner's statement of reasons for allowance, contained in the Notice of Allowance mailed July 21, 2006 in that the prior art of record fails to disclose, teach or suggest the claimed invention. However, Applicants note that the Examiner's statement fails to address all limitations of all of the allowed claims. For example, certain claim limitations were not discussed in the Examiner's Reasons for Allowance, including those in most of the allowed claims, each of which defines a unique combination of features not shown or suggested by the prior art, providing additional reasons for allowance of each claim.

Furthermore, Applicants respectfully submits that the scope of the claimed invention should not be limited by the Examiner's statement, but rather the scope of the claimed invention should be based on the actual language of the allowed claims.

Dated: August 22, 2006

Respectfully submitted,

By  _____

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